



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of

Adrien Dromard et al.

Application No.: 10/583,417

Filing Date: April 26, 2007

Title: HIGHLY-STRUCTURED SILICA  
HAVING A LOW WATER UPTAKE,  
PREPARATION METHOD THEREOF  
AND USES OF THE SAME

) **Mail Stop AMENDMENT**

) Group Art Unit: 1793

) Examiner: Serena L. Hanor

) Confirmation No.: 3689

**FIRST  
INFORMATION DISCLOSURE STATEMENT  
TRANSMITTAL LETTER**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

Enclosed is a FIRST Information Disclosure Statement (IDS) and accompanying form PTO-1449 for the above-identified patent application.

- ☐ No additional fee for submission of an IDS is required.
- ☒ The fee of \$ 180 as set forth in 37 C.F.R. § 1.17(p) is also enclosed.
- ☐ A statement under 37 C.F.R. § 1.97(e) is also enclosed.
- ☐ A statement under 37 C.F.R. § 1.97(e), and the fee of \$ 180 as set forth in 37 C.F.R. § 1.17(p) are also enclosed.
- ☐ Charge \_\_\_\_\_ to Deposit Account No. 02-4800 for the fee due.
- ☐ A check in the amount of \_\_\_\_\_ is enclosed for the fee due.
- ☒ Charge \$ 180 to credit card for the fee due. Form PTO-2038 is attached.
- ☒ The Director is hereby authorized to charge any appropriate fees under 37 C.F.R. §§ 1.16, 1.17 and 1.21 that may be required by this paper, and to credit any overpayment, to Deposit Account No. 02-4800. This paper is submitted in duplicate.

Respectfully submitted,

BUCHANAN INGERSOLL & ROONEY PC

Date August 17, 2009

By: 

Scott W. Cummings  
Registration No. 41,567

P.O. Box 1404  
Alexandria, VA 22313-1404  
703 836 6620